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Shooting earmuff

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Description

- (1) FIG. **1** is a top perspective view of a shooting earmuff, showing my new design;
- (2) FIG. **2** is a bottom perspective view thereof;
- (3) FIG. **3** is a front view thereof;
- (4) FIG. **4** is a rear view thereof;
- (5) FIG. **5** is a left side view thereof;
- (6) FIG. **6** is a right side view thereof;
- (7) FIG. **7** is a top view thereof;
- (8) FIG. **8** is a bottom view thereof;

- (9) FIG. **9** is its folded state diagram;
- (10) FIG. **10** is an enlarged detail view of area **10** in FIG. **1**;
- (11) FIG. **11** is an enlarged detail view of area **11** in FIG. **1**;
- (12) FIG. 12 is an enlarged detail view of area 12 in FIG. 2; and,
- (13) FIG. **13** is an enlarged detail view of area **13** in FIG. **5**.
- (14) The broken lines in the drawings illustrate the portions of the shooting earmuff, which form no part of the claimed design.
- (15) The dash-dot-dash broken lines encircling the enlarged views are for annotative purposes only and form no part of the claim thereof.

Claims

The ornamental design for a shooting earmuff, as shown and described.